PROGRAMME

Time	Agenda	
0800	Registration	
0830	Breakfast	
0900	Opening Address by Prof Uda, Director of INEE, UniMAP.	
0915	Opening Address by Raith Asia	
0930	Introduction to nano technology and related semiconductor processes	
1030	Lithography techniques overview	
1130	E-beam lithography techniques	
1230	Lunch	
1400	E-beam Lithography Applications	
1500	Presentation by INEE	
1530	Advanced E-beam Lithography Applications	
1630	Tea Break and End of Workshop	

REGISTRATION

Registration before 30th April 2010. F	RM50/pax (only 50 seating available)
NAME:	
ORGANIZATION	
ADDRESS:	
DESIGNATION:	
TEL OFFICE:	
FAX:	

METHOD OF PAYMENT

Bank Draft/Cheque/Money Order No:

Bank Draft or Cheque must be made payable to:

"Bendahari UniMAP" (note: "Nano Lithography by E-beam Lithography Solutions" or cash invoice must be Bank in (Muamalat Bank) under Account

Name: **BENDAHARI UniMAP** (Acc. No.: 0901-0001-2347-10).

INEE Lab Tour

Send by courier or registered mail to:

Ms Raja Raina Sacha

INSTITUTE OF NANO ELECTRONIC ENGINEERING UNIVERSITI MALAYSIA PERLIS

Lot 106, 108 & 110, Tingkat 1, Blok A Taman Pertiwi Indah, Jalan Kangar - Alor Setar Seriab, 01000 Kangar Perlis Indera Kayangan



UNIVERSITI MALAYSIA PERLIS



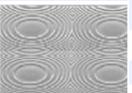


1-Day Intensive NANOLITHOGRAPHY WORKSHOP ASIA

'ELECTRON BEAM LITHOGRAPHY SOLUTIONS CONCEPT'







By:

Universiti Malaysia Perlis (UniMAP)

11th May (Tuesday) 2010

Venue:

Dewan Kuliah DKP1 Pusat Kejuruteraan Kuala Perlis Universiti Malaysia Perlis

Jointly organized by:

INSTITUTE OF NANO ELECTRONIC ENGINEERING UNIVERSITI MALAYSIA PERLIS

Lot 106, 108 & 110, Tingkat 1, Blok A
Taman Pertiwi Indah, Jalan Kangar - Alor Setar
Seriab, 01000 Kangar
Perlis Indera Kayangan www.unimap.edu.my

Enquiries to:

Tel: +604-9798581 Fax: +604-9798578 Mobile: +6012-426-9060 (Sacha) Email: sacha@unimap.edu.my

Raith Asia Ltd.

Two Chinachem Exchange Square No. 338 King's Road Floor 11, Unit 03

North Point Hong Kong

Phone: +852 2887 6828 (Andre Linden)

Fax: +852 6627 0368

Email: linden@raithasia.com.hk
Online registration at www.raith.com



GPS coordinate : N 6°23' 17.43" E 100°08' 28.70"





'NANO-LITHOGRAPHY BY E-BEAM LITHOGRAPHY SOLUTIONS'

ABSTRACT

The purpose of the workshop is to educate thepeople in scientific research on the most advanced nano-fabrication technology, the electron beam nanolithography. The target audience are researchers, scientists in universities and research institutes involved in scientific research. Such as Nano-electronics, Nano-photonics, Quantum Physics, Material Science, Nano-magnetism, NEMS, Nano-biotechnology, etc. Raith regularly host training courses, workshops and user meetings for its customers to help them to operate their Raith systems, to share applications information and to discuss their scientific results.

ABOUT RAITH

Mission

Identity

Raith is an independent high technology enterprise, which, develops, sells, delivers and supports products to an international client base. The company has pioneered markets for new products, and offers significant customer benefits, enabling leading edge innovation in technology. The success story is based on identifying latest market trends, which is possible by our highly skilled, motivated and multicultural team. The target being to gain a substantial annual profitable growth rate.

Markets

Raith offers innovative solutions for nanolithography and -fabrication with emphasis on R&D and small batch production for growing markets. Raith is a partner in the semiconductor industry, microsystem technology and original equipment manufacturers. Proprietary solutions exist for <u>failure analysis</u>, inspection and analytics. Within targeted markets we aim to lead with excellence.

Secure customers investments

Since 1980 Raith has invested people and new products, maintaining close contact to customers with leading edge applications. The development of personal relations and professional local support secures customers investments in Raith products.